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Stylesheet Version v1.1.0

Title of Invention	LOW-K DIELECTRIC MATERIAL BASED UPON CARBON NANOTUBES AND METHODS OF FORMING SUCH LOW-K DIELECTRIC MATERIALS	
Application Number :		
Date :		
First Named Applicant:	Toshiharu Furukawa	
Confirmation Number:		
Attorney Docket Number:	BUR920040152US1	
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Documents being submitted:	Files
us-request	BUR920040152US1-usrequ.xml us-request.dtd us-request.xsl
us-assignment	BUR920040152US1-usassn.xml us-assignment.xsl us-assignment.dtd BUR920040152ASSIGN1.tif BUR920040152ASSIGN2.tif
us-fee-sheet	BUR920040152US1-usfees.xml us-fee-sheet.xsl us-fee-sheet.dtd
us-declaration	BUR920040152DEC1.tif
us-declaration	BUR920040152DEC2.tif
application-body	BUR920040152ABX.xml application-body.dtd Image1.tif Image2.tif Image3.tif Image4.tif Image5.tif Image6.tif Image7.tif Image8.tif Image9.tif isoamsa.ent isoamsb.ent isoamsc.ent isoamsn.ent isoamso.ent isoamsr.ent isobox.ent isocyr1.ent isocyr2.ent isodia.ent isogr1.ent isogr2.ent isogr3.ent isogr4.ent isolat1.ent isolat2.ent isomfrk.ent isomopf.ent isomscr.ent isonum.ent isopub.ent isotech.ent mathml2.dtd mathml2-qname-1.mod mmlalias.ent

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Comments	
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